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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/698,429	11/03/2003	Erez N. Ribak	27029 .	9415	
7	7590 06/30/2004		EXAM	NER	
G. E. EHRLICH (1995) LTD. c/o ANTHONY CASTORINA			CHOI, WILLIAM C		
SUITE 207	I CASTORINA		ART UNIT	PAPER NUMBER	
2001 JEFFERSON DAVIS HIGHWAY ARLINGTON, VA 22202			2873		
ARLINGTON	, VA 22202		DATE MAILED: 06/30/2004	1	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)			
		10/698,429	RIBAK, EREZ N.	BX		
Office Action Summary		Examiner	Art Unit			
		William C. Choi	2873			
Th MAILING DATE of Period for Reply	this communication app	ears on the cover sheet with th	corr spondenc addre	ss		
THE MAILING DATE OF THI - Extensions of time may be available up after SIX (6) MONTHS from the mailing if the period for reply specified above in the set or extended the set of extended the set or extended the set of extended	S COMMUNICATION. Inder the provisions of 37 CFR 1.13 Inder the provisions of 37 CFR 1.13 Index of this communication. Inde	'IS SET TO EXPIRE 3 MONTH (6(a). In no event, however, may a reply be to within the statutory minimum of thirty (30) da ill apply and will expire SIX (6) MONTHS fror cause the application to become ABANDON date of this communication, even if timely file	imely filed ys will be considered timely. n the mailing date of this commi ED (35 U.S.C. § 133).	unication.		
Status						
1) Responsive to commu	nication(s) filed on 08 De	ecember 2003.				
2a) This action is FINAL .	• •	action is non-final.				
3) Since this application is	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims						
5)⊠ Claim(s) <u>15-17</u> is/are a 6)⊠ Claim(s) <u>12-14</u> is/are n 7)□ Claim(s) is/are o	(s) is/are withdrav illowed. ejected.	vn from consideration.				
Application Papers						
Applicant may not reques	08 December 2003 is/ast that any objection to the cet(s) including the correction	r. re: a)⊠ accepted or b)□ object drawing(s) be held in abeyance. Solion is required if the drawing(s) is o aminer. Note the attached Office	ee 37 CFR 1.85(a). bjected to. See 37 CFR 1	1.121(d).		
Priority under 35 U.S.C. § 119						
a) All b) Some * c) 1. Certified copies 2. Certified copies 3. Copies of the ce application from	None of: of the priority documents of the priority documents rtified copies of the prior the International Bureau	s have been received in Applicative documents have been receive	ntion No ved in this National Sta	age		
Attachment(s) 1) Notice of References Cited (PTO-2) Notice of Draftsperson's Patent Draftsperson's Patent Draftsperson's Patent Draftsper No(s)/Mail Date	awing Review (PTO-948)	4) Interview Summar Paper No(s)/Mail I 5) Notice of Informal 6) Other:		i2)		

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DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 12-14 are rejected under 35 U.S.C. 102(b) as being anticipated by Kurtz et al (U.S. 5,569,626).

In regard to claim 12, Kurtz discloses a method of straining a porous crystalline material element (column 3, lines 34-36, Figure 1A, "18", re silicon) comprising the step of subjecting a porous crystalline material to light (column 4, lines 16-19, Figure 1A).

In regard to claim 13, Kurtz discloses a method, which would inherently relax a strained porous crystalline material element, this being reasonably assumed from Kurtz disclosing variable amounts of stress being applied to the element (column 4, lines 26-28). Kurtz further discloses wherein said element is subjected to light (column 4, lines 16-19, Figure 1A) and wherein said method would inherently comprise the step of preventing the light from impinging on the strained porous crystalline material element (i.e. by turning off the light source).

In regard to claim 14, Kurtz discloses a piezooptic device (column 3, lines 14-17, Figure 1A) comprising an element of porous crystalline material (column 3, lines 34-36, Figure 1A, "18", re silicon) and at least one light source being in a lighting distance

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therefrom and subjecting said element to light via said light source (column 4, lines 8-19, Figure 1A). Although the reference of Kurtz doesn't specifically mention the strain, because Kurtz meets all the limitations of the claim, subjecting said element to light via said light source would inherently result in a strain developing in said element.

Allowable Subject Matter

Claims 15-17 are allowed.

The following is a statement of reasons for the indication of allowable subject matter: The prior art fails to teach a combination of all the claimed features as presented in claims 15-17: a method of inducing strain in a first element as claimed, specifically comprising the steps of attaching to the first element, or integrally forming with the first element, a second element of porous crystalline material and subjecting said second element to light.

Prior Art Citations

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Brody (U.S. 4,524,294) is being cited herein to show piezooptic device comprising some of the structural limitations of that of the claimed invention, but do not specifically disclose a porous crystalline material as claimed.

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to William C. Choi whose telephone number is (571) 272-2324. The examiner can normally be reached on Monday-Friday from about 9:00 am to 6 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Georgia Y. Epps can be reached on (571) 272-2328. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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William Choi Patent Examiner Art Unit 2873 June 24, 2004

> Supervisory Patent Examiner Technology Center 2800